



Seat number

King Mongkut's University of Technology Thonburi
Midterm Examination

Physics Semester 2 – Academic Year 2012

Subject: EIE 311 Electronic Materials and Devices

For: Electronics and Telecommunication students, 3rd Yr (International Program)

Exam Date: Monday 4th March, 2013

Time: 13:00-16:00 hrs.

Instructions:-

1. This exam consists of 5 problems with a total of 6 pages, including the cover.
2. This exam is a closed-book/closed-note exam.
3. Answer each problem on the given booklet.
4. A calculator compiling with the university rule is allowed.
5. **Do not** bring any exam papers and answer sheets **outside** the exam room.
6. Please do your work to 4 significant figures.
7. Formula sheets are allowed to be parted from the exam.

Remarks:-

- Raise your hand when you finish the exam to ask for a permission to leave the exam room.
- Students who fail to follow the exam instruction might eventually result in a failure of the class or may receive the highest punishment with university rules.
- Carefully read the entire exam before you start to solve problems. Before jumping into the mathematics, think about what the question is asking. Investing a few minutes of thought may allow you to avoid twenty minutes of needless calculation!

Exam No.	1	2	3	4	5	TOTAL
Full Score	20	20	20	20	20	100
Graded Score						

Name _____ Student ID _____

This examination is designed by
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This examination has been approved by the committees of the ENE department.

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1. (20 points) The Hall Effect experiment shown in figure 1 has following parameters:

$L = 0.1$ cm, $W = 0.01$ cm, $d = 0.001$ cm, $I_x = 1$ mA, $V_x = 12.5$ V, $B_z = 500$ gauss, and $V_H = -6.25$ mV.

Determine: a) Hall field (E_H) b) Are majority carriers 'holes' or 'electrons'? Please explain your reason. c) Majority carrier concentration and its mobility.

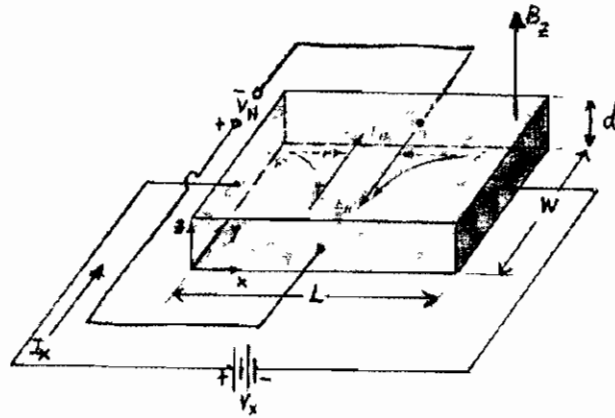


Fig. 1 Hall Effect setup.

2. (20 points) An electron is bound in a one-dimensional infinite potential well with a width of 10 \AA .
- Calculate the first three energy levels that the electron may occupy.
 - If the electron drops from the third to the second energy level, what is the wavelength of a photon that might be emitted?
3. (20 points) Find
- The Miller indices for the following planes in figure 2 and 3.
- Note: a , b , and c correspond to x -, y -, and z - axes, respectively.

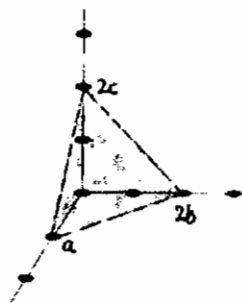


Fig. 2

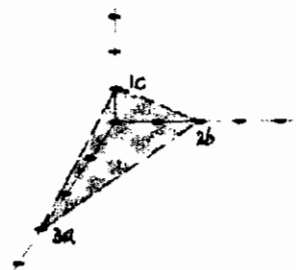


Fig. 3

- b) What is the structure of a cubic in figure 4? Also, calculate the surface density of atoms on the (110) plane in the unit of atoms/cm². Note: A lattice constant is 5 Å.

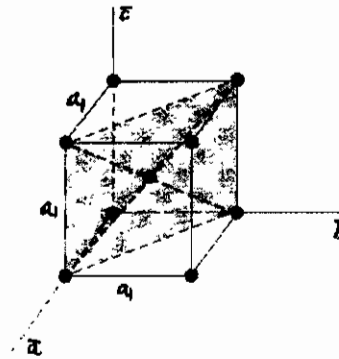


Fig. 4

4. (20 points) Determine
- The probability that an energy state at $3kT$ above E_F is occupied by an electron.
 - The temperature at which there is a 1 percent probability that a state 0.3 eV below E_F will NOT contain any electron.
5. (20 points)
- Calculate the hole concentration in silicon at $T = 400$ K. Assume that the Fermi energy is 0.27 eV above the valence band.
 - Calculate the electron and hole concentrations in silicon at room temperature in which $N_D = 10^{16} \text{ cm}^{-3}$ and $N_A = 0$.
 - Consider silicon at room temperature with doping concentrations of $N_D = 8 \times 10^{15} \text{ cm}^{-3}$ and $N_A = 5 \times 10^{15} \text{ cm}^{-3}$. Determine the position of the Fermi energy level.

Properties of Si and GaAs at 300 K

Properties	Si	GaAs
Atoms/cm ³	5.02×10^{22}	4.42×10^{22}
Atomic weight	28.09	144.63
Breakdown field (V/cm)	$\sim 3 \times 10^5$	$\sim 4 \times 10^5$
Crystal structure	Diamond	Zincblende
Density (g/cm ³)	2.329	5.317
Dielectric constant	11.9	12.4
Effective density of states in conduction band, N_C (cm ⁻³)	2.86×10^{19}	4.7×10^{17}
Effective density of states in valence band, N_V (cm ⁻³)	2.66×10^{19}	7.0×10^{18}
Effective mass (conductivity)		
Electrons (m_e/m_0)		
Holes (m_h/m_0)		
Electron affinity, χ (V)	4.05	4.07
Energy gap (eV)	1.12	1.42
Index of refraction	3.42	3.3
Intrinsic carrier concentration(cm ⁻³)	9.65×10^9	2.25×10^6
Intrinsic resistivity (Ω -cm)	3.3×10^5	2.9×10^8
Lattice constant (\AA)	5.43102	5.65325
Linear coefficient of thermal expansion, $\Delta L/L \times T$ ($^{\circ}\text{C}^{-1}$)	2.59×10^{-6}	5.75×10^{-6}
Melting point ($^{\circ}\text{C}$)	1412	1240
Minority-carrier lifetime (s)	3×10^{-2}	$\sim 10^{-8}$
Mobility (cm ² /V·s)		
μ_n (electrons)	1450	9200
μ_p (holes)	505	320
Specific heat (J/g· $^{\circ}\text{C}$)	0.7	0.35
Thermal conductivity(W/cm-K)	1.31	0.46
Vapor pressure (Pa)	1 at 1650°C 10^{-6} at 900°C	100 at 1050°C 1 at 900°C

Formula sheet (1/2)

N_A = Avogadro's number = 6.02×10^{23} atoms/mole

k = Boltzmann's constant = 1.38×10^{-23} J/K

q = electronic charge = 1.6×10^{-19} C

eV = electronvolt = 1.6×10^{-19} J

m_0 = free electron mass = 9.11×10^{-31} kg.

ϵ_0 = permittivity of free space = 8.85×10^{-12} F/m = 8.85×10^{-14} F/cm

μ_0 = permeability of free space = 1.26×10^{-6} H/m

h = Planck's constant = 6.63×10^{-34} J.s

c = light velocity (speed) = 3×10^8 m/s

1 Gauss = 1×10^{-4} Wb/m² = 1×10^{-4} Tesla

$$R = \frac{\rho l}{A} = \frac{1}{\sigma} \cdot \frac{l}{A}$$

$$J = \sigma E \quad v_D = \mu_e E$$

$$J = N_e \cdot q \cdot v_D$$

$$\sigma = \sigma_e + \sigma_h$$

$$\rho = \frac{1}{qn\mu_e + qp\mu_h}$$

$$E_H = \frac{B \cdot j}{N_e q}$$

$$\frac{1}{\mu} = \frac{1}{\mu_L} + \frac{1}{\mu_I}$$

$$R_H = -\frac{1}{qN_e} = \frac{1}{N_e e}$$

$$V_H = E_H L$$

$$J_e = -qF = qD_n \frac{dn}{dx}$$

$$D_n = \left(\frac{kT}{q} \right) \mu_e$$

$$\lambda = \frac{h}{p}$$

$$\frac{d^2\psi}{dx^2} + \frac{2m}{\hbar^2} (E - V) \psi = 0$$

$$E_n = \frac{n^2 \hbar^2}{8mL^2}$$

$$E = h\nu = \frac{hc}{\lambda}$$

$$T \cong \exp \left\{ -2d \sqrt{\frac{2m_e^* (qV_0 - E)}{\hbar^2}} \right\}$$

$$\rho = \left(\frac{nM}{N_A} \right) \cdot \frac{1}{a^3}$$

$$\cos(ka) = \frac{P \sin(\alpha a)}{\alpha a} + \cos(\alpha a)$$

$$P = \frac{maV_0 w}{\hbar^2}$$

$$\alpha = \frac{1}{\hbar} \sqrt{2mE}$$

Formula sheet (2/2)

$$E_n = -\frac{mq^4}{8\epsilon_0^2 h^2} \cdot \frac{1}{n^2} = -\frac{13.6 \text{ eV}}{n^2}$$

$$n = \int_0^\infty n(E) d(E) = \int_0^\infty N(E) F(E) dE$$

$$N(E) = 4\pi \left(\frac{2m}{h^2} \right)^{3/2} E^{1/2}$$

$$F(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

$$n = N_C \exp[-(E_C - E_F)/kT]$$

$$p = N_V \exp[-(E_F - E_V)/kT]$$

$$n_i = \sqrt{N_C N_V} \exp(-E_g/2kT)$$

$$n, p = n_i^2$$

$$N_C = 2 \left(2\pi m_e^* kT / h^2 \right)^{3/2}$$

$$N_V = 2 \left(2\pi m_h^* kT / h^2 \right)^{3/2}$$

$$E_F = E_i = (E_C + E_V)/2 + (kT/2) \ln(N_V / N_C)$$

$$E = \frac{-m^* e^4}{8(\epsilon_0 \epsilon_r)^2 h^2}$$

$$N_D^+ = N_D [1 - F(E_D)]$$

$$N_A^- = N_A F(E_A)$$

$$n = n_i \exp[(E_F - E_i)/kT]$$

$$p = n_i \exp[(E_i - E_F)/kT]$$

	Sb	P	As	Ti	C	Pt	Au	O
Si	0.039	0.045	0.054	0.21	0.25	0.25		0.16
								0.38
								0.51
1.12							0.54	0.41
							A	
				0.34	0.35	0.36		
					D			
	0.045	0.067	0.072	0.16		0.3	0.29	
	B	Al	Ga	In	Pd		D	

- Good luck for all your midterm exams -